- Medium-Resolution, Solid-State Image Sensor for Low-Cost Color TV Applications
- 324(H) x 243(V) Active Elements in Image Sensing Area
- 10-μm Square Pixels
- Small Size
- Low Cost
- Fast Clear Capability
- Electronic Shutter Function From 1/60–1/50000 s
- Low Dark Current
- Electron-Hole Recombination Antiblooming
- Dynamic Range . . . 66 dB Typical
- High Sensitivity
- High Blue Response
- 8-Pin Dual-In-Line Plastic Package
- 4-mm Image-Area Diagonal
- Solid-State Reliability With No Image Burn-In, Residual Imaging, Image Distortion, Image Lag, or Microphonics

DUAL-IN-LINE PACKAGE (TOP VIEW) IAG2 **ABG** 8 ADB IAG1 2 7 SUB 3 6 SAG SRG OUT 5

description

The TC254P is a frame-transfer charge-coupled device (CCD) designed for use in color NTSC TV and special-purpose applications requiring low cost and small size.

The image-sensing area of the TC254P is configured in 243 lines with 336 elements in each line. Twelve elements are provided in each line for dark reference. The blooming-protection feature of the sensor is based on recombining excess charge with charge of opposite polarity in the substrate. This antiblooming is activated by supplying clocking pulses to the antiblooming gate, which is an integral part of each image-sensing element.

The sensor can be operated in a non-interlace mode as a 324(H) by 243(V) square color pixel mode by alternately averaging two red pixels for red pixels and two blue pixels for blue pixels. Because the human eye is most sensitive to the green light wavelength, the 324×243 resolution is preserved due to the orientation of the green pixels in the Bayer mosaic color filter pattern.

The device can also be operated in a 162(H) by 121(V) square color pixel mode by utilizing a separate red, two averaged greens, and a blue pixel for each color pixel. In this mode, true interlaced video is possible, effectively increasing the vertical resolution, by performing a one pixel shift during the off-chip video processing.

One important aspect of this image sensor is its high-speed image-transfer capability. This capability allows for an electronic shutter function comparable to interline-transfer and frame-interline-transfer sensors without the loss of sensitivity and resolution inherent in those technologies.



This MOS device contains limited built-in gate protection. During storage or handling, the device leads should be shorted together or the device should be placed in conductive foam. In a circuit, unused inputs should always be connected to SUB. Under no circumstances should pin voltages exceed absolute maximum ratings. Avoid shorting OUTn to ADB during operation to prevent damage to the amplifier. The device can also be damaged if the output terminals are reverse-biased and an excessive current is

allowed to flow. Specific guidelines for handling devices of this type are contained in the publication *Guidelines for Handling Electrostatic-Discharge-Sensitive (ESDS) Devices and Assemblies* available from Texas Instruments.

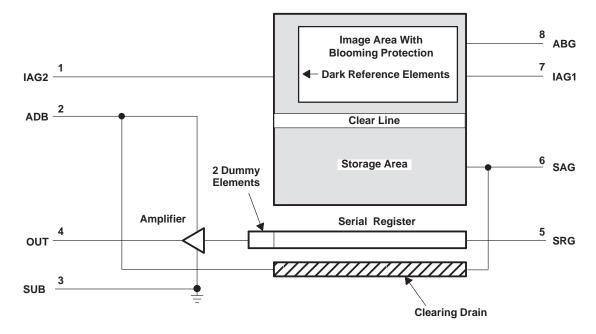


description (continued)

Charge is converted to signal voltage with a $12-\mu V$ per electron conversion factor by a high-performance charge-detection structure with built-in automatic reset and a voltage reference generator. The signal is buffered by a low-noise two-stage source-follower amplifier to provide high output-drive capability.

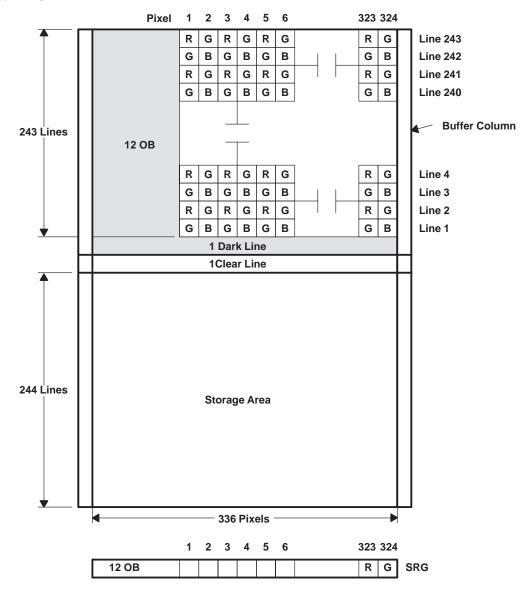
The TC254P is built using TI-proprietary virtual-phase technology, which provides devices with high blue response, low dark current, high photoresponse uniformity, and single-phase clocking. The TC254P is characterized for operation from -10° C to 45° C.

functional block diagram





sensor topology diagram



OB = Optical Black R = Red

B = Blue

G = Green

Terminal Functions

TERM	TERMINAL		DESCRIPTION	
NAME	NO.	I/O	DESCRIPTION	
ABG	8	I	Antiblooming gate	
ADB	2	I	Supply voltage for amplifier-drain bias	
SUB	3		Substrate	
IAG1	7	I	Image-area gate 1	
IAG2	1	I	Image-area gate 2	
OUT	4	0	Output	
SAG	6	Ī	Storage-area gate	
SRG	5	Ī	Serial-register gate	

detailed description

The TC254P consists of five basic functional blocks: (1) the image-sensing area, (2) the image-clear line, (3) the storage area, (4) the serial register, and (5) the charge-detection node and output amplifier.

image-sensing area

Cross sections with potential well diagrams and top views of image-sensing and storage-area elements are shown in Figure 1 and Figure 2. As light enters the silicon in the image-sensing area, free electrons are generated and collected in the potential wells of the sensing elements. During this time, the antiblooming gate is activated by the application of a burst of pulses every horizontal blanking interval. This prevents blooming caused by the spilling of charge from overexposed elements into neighboring elements. Twelve columns of shielded-from-light elements on the left edge of the image-sensing area generate the dark reference necessary in subsequent video processing circuits for restoration of the video-black level. There is also one column of elements on the right side of the image-sensing area and one line between the image-sensing area and the image-clearing line.

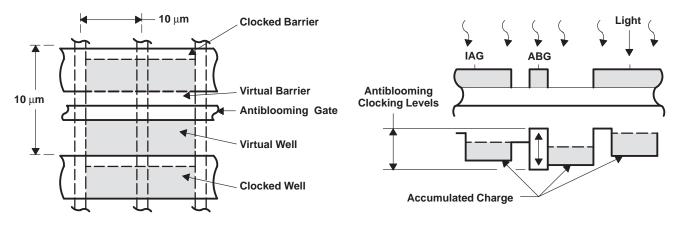


Figure 1. Charge-Accumulation Process

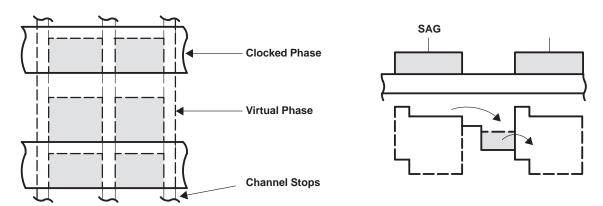


Figure 2. Charge-Transfer Process

image-clear line

During start-up or electronic-shutter operations, it is necessary to clear the image area of charge without transferring it to the storage area. In such situations, the two-image area gates are clocked 244 times without clocking the storage-area gate. The charge in the image area is then cleared through the image-clear line.



storage area

After exposure, the charge captured in each image-area is transferred through the image clear line to the storage area. The stored charge is then transferred line by line into the serial register for readout. Figure 3 illustrates the timing to (1) transfer the image to the storage area, and (2) to transfer each line from the storage area to the serial register.

serial register

Each line, after it is clocked into the serial register, is read out pixel by pixel. Figure 3 illustrates the serial-register clock sequence.

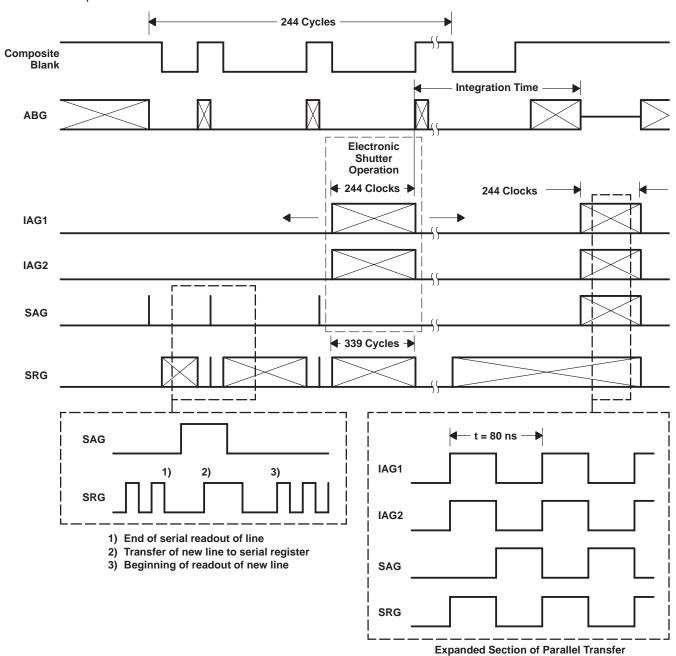


Figure 3. Timing Diagram



charge-detection node and output amplifier

The buffer amplifier converts the charge into a video signal. Figure 4 shows the circuit diagram of the charge-detection node and output amplifier. As charge is transferred into the detection node, the potential of this node changes in proportion to the amount of signal received. This change is sensed by a MOS transistor and, after proper buffering, the signal is supplied to the output terminal of the image sensor. After the potential change is sensed, the node is reset to a reference voltage supplied by an on-chip reference generator. The reset is accomplished by a reset gate that is connected internally to the serial register. The detection node and buffer amplifier are located a short distance away from the edge of the storage area; therefore, two dummy cells are used to span this distance.

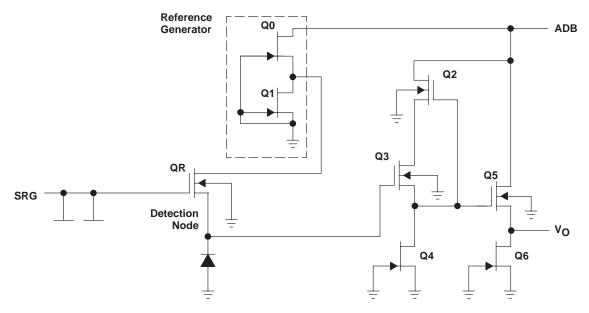


Figure 4. Buffer Amplifier and Charge-Detection Node



spurious-nonuniformity specification

The spurious-nonuniformity specification of the TC254P is based on several sensor characteristics:

- Amplitude of the nonuniform pixel
- Polarity of the nonuniform pixel
 - Black
 - White
- Column amplitude

The CCD sensor is characterized in both an illuminated condition and a dark condition. In the dark condition, the nonuniformity is specified in terms of absolute amplitude, as shown in Figure 5. In the illuminated condition, the nonuniformity is specified as a percentage of the total illumination, as shown in Figure 6.

The specification for the TC254P is as follows:

WHITE SPOT	WHITE SPOT	COLUMN	COLUMN	BLACK SPOT	WHITE/BLACK†	
(DARK)	(ILLUMINATED)	(DARK)	(ILLUMINATED)	(ILLUMINATED)	PAIR	
x < 15 mV	x < 15%	x < 0.5 mV	x < 1 mV	x < 15%	x < 9mV	

[†] A white/black pair nonuniformity will be no more than 2 pixels even for integration times of 1/60 second.

The conditions under which this specification is defined are as follows:

- The integration time is 1/60 second except for illuminated white spots, illuminated black spots, and white/black pair nonuniformities; in these three cases, the integration time is 1/120 second.
- The temperature is 45°C.
- The CCD video-output signal is 60 mV ± 10 mV.

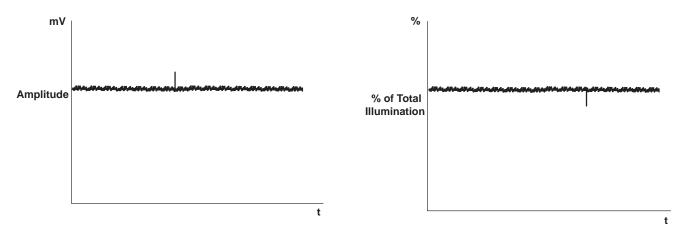


Figure 5. Pixel Nonuniformity, Dark Condition

Figure 6. Pixel Nonuniformity, Illuminated Condition

absolute maximum ratings over operating free-air temperature (unless otherwise noted)†

recommended operating conditions

			MIN	NOM	MAX	UNIT
Supply voltage, V _{CC}	ADB	ADB			13	V
Substrate bias voltage				0		V
	IAG1, IAG2	High level	1.5	2	2.5	
	IAG1, IAG2	Low level	-10.5	-10	-9.5	
	SAG	High level	1.5	2	2.5	
	SAG	Low level	-10.5	-10	-9.5	V
Input voltage, V _I	SRG	High level	1.5	2	2.5	
	SKG	Low level	-10.5	-10	-9.5	
		High level	3.5	4	4.5	
	ABG	Intermediate level‡		-2.5		
		Low level	-8	-7	-6	
	ABG			6.25	12.5	
Clock frequency f	IAG1, IAG2				25	MHz
Clock frequency, f _{clock}	SAG				12.5	IVITIZ
	SRG			6.25	12.5	
Load capacitance	OUT				6	pF
Plastic package thermal conductivity						J/cm•s•°C
Operating free-air temperature, TA	Operating free-air temperature, T _A				45	°C

[‡] Adjustment is required for optimum performance.



[†] Stresses beyond those listed under "absolute maximum ratings" may cause permanent damage to the device. These are stress ratings only, and functional operation of the device at these or any other conditions beyond those indicated under "recommended operating conditions" is not implied. Exposure to absolute-maximum-rated conditions for extended periods may affect device reliability.

NOTE 1: All voltages are with respect to the substrate terminal.

electrical characteristics over recommended operating ranges of supply voltage and free-air temperature (unless otherwise noted)

PARAMETER			TYP	MAX	UNIT
Dynamic range (see Note 2)	Antiblooming disabled (see Note 3)		66		dB
Charge-conversion factor	•	11	12	13	μV/e
Charge-transfer efficiency (see Note 4)			0.9999	1	
Signal-response delay time, τ (see Note 5)			20		ns
Gamma (see Note 6)		0.97	0.98	0.99	
Output resistance			350		Ω
Noise-equivalent signal without correlated double sampling			62		electrons
Noise-equivalent signal with correlated double sampling (see Note 7)			31		electrons
	ADB (see Note 8)	13	15	18	dB
Rejection ratio	SRG (see Note 9)		50		
	ABG (see Note 10)		40		
Supply current		5	10	mA	
	IAG1, IAG2		1000		pF
Innut conscitones C	SRG		22		
Input capacitance, C _i	ABG		850		
	SAG		2000		

NOTES: 2. Dynamic range is – 20 times the logarithm of the mean-noise signal divided by saturation-output signal.

- 3. For this test, the antiblooming gate must be biased at the intermediate level.
- 4. Charge-transfer efficiency is one minus the charge loss per transfer in the output register. The test is performed in the dark using an electrical-input signal.
- 5. Signal-response delay time is the time between the falling edge of the SRG pulse and the output-signal valid state.
- 6. Gamma (γ) is the value of the exponent in the equation below for two points on the linear portion of the transfer-function curve (this value represents points near saturation).

$$\left(\frac{\text{Exposure (2)}}{\text{Exposure (1)}}\right)^{\gamma} = \left(\frac{\text{Output signal (2)}}{\text{Output signal (1)}}\right)$$

- 7. A three-level serial-gate clock is necessary to implement correlated double sampling.
- 8. ADB rejection ratio is -20 times the logarithm of the ac amplitude at the output divided by the ac amplitude at ADB. See Figure 7 for measured ADB rejection ratio as a function of frequency.
- 9. SRG rejection ratio is -20 times the logarithm of the ac amplitude at the output divided by the ac amplitude at SRG.
- 10. ABG rejection ratio is -20 times the logarithm of the ac amplitude at the output divided by the ac amplitude at ABG.

optical characteristics, $T_A = 40^{\circ}C$ (unless otherwise noted)

	PARAMETER	MIN	TYP	MAX	UNIT
	Red with CM500 IR filter		9.5		
Sensitivity [†]	Green with CM500 IR filter		10		mV/lux
	Blue with CM500 IR filter		7		
Saturation signal, V _{sat} (see Note 11)	Antiblooming disabled, Interlace off	600	750		mV
Maximum usable signal, V _{use}	Antiblooming enabled	200	250		mV
Blooming-overload ratio (see Note 12)	100	200			
Image-area well capacity		43000	62500		electrons
Smear (see Notes 13 and 14)			0.00012		
Dark current	Interlace disabled, $T_A = 21^{\circ}C$		0.20		nA/cm ²
Dark signal			200		μV
Pixel uniformity	Output signal = 60 mV ± 10 mV		15		mV
Column uniformity	Output signal = 60 mV ± 10 mV		0.5		mV
Shading		15		%	
Electronic-shutter capability	1/15000	1/60		s	

[†] Standard illuminates 2856K

NOTES: 11. Saturation is the condition in which further increase in exposure does not lead to further increase in output signal.

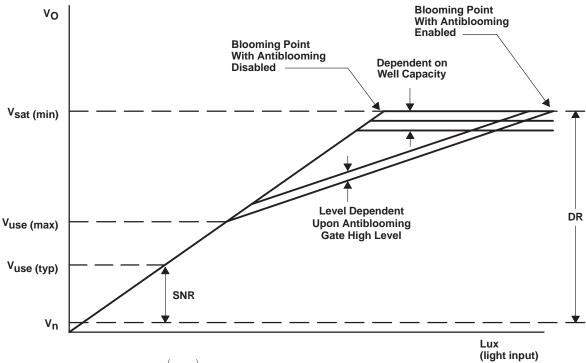
- 12. Blooming is the condition in which charge is induced in an element by light incident on another element. Blooming-overload ratio is the ratio of blooming exposure to saturation exposure.
- 13. Smear is a measure of the error introduced by transferring charge through an illuminated pixel in shutterless operation. It is equivalent to the ratio of the single-pixel transfer time to the exposure time using an illuminated section that is 1/10 of the image area vertical height with recommended clock frequencies.
- 14. The exposure time is 16.67 ms, the fast-dump clocking rate during vertical transfer is 12.5 MHz, and the illuminated section is 1/10 of the height of the image section.

timing requirements

			MIN	NOM	MAX	UNIT
		ABG	10	40		
		IAG1, IAG2 (fast clear)	10	10		
t _r	Rise time	IAG1, IAG2 (image transfer)	10	20		ns
		SAG	10	20		
		SRG	10	40		
		ABG	10	40		
		IAG1, IAG2 (fast clear)	10	10		
t _f	Fall time	IAG1, IAG2 (image transfer)	10	20		ns
		SAG	10	20		
		SRG	10	40		



PARAMETER MEASUREMENT INFORMATION



DR (dynamic range) = 20 log
$$\frac{(V_{sat})}{V_{n}}$$
 ∂B

SNR (signal-to-noise-rate) = 20 log
$$\frac{(V_{use})}{V_{n}} \partial B$$

V_n = noise-floor voltage

V_{sat (min)} = minimum saturation voltage

Vuse (max) = maximum usable voltage

V_{use} (typ) = typical user voltage (camera white clip)

NOTES: A. V_{use (typ)} is defined as the voltage determined to equal the camera white clip. This voltage must be less than V_{use} (max).

(max).
B. A system trade-off is necessary to determine the system light sensitivity versus the signal/noise ratio. By lowering the V_{use} (typ),

the light sensitivity of the camera is increased; however, this sacrifices the signal/noise ratio of the camera.

Figure 7. Typical V_{sat}, V_{use} Relationship

PARAMETER MEASUREMENT INFORMATION

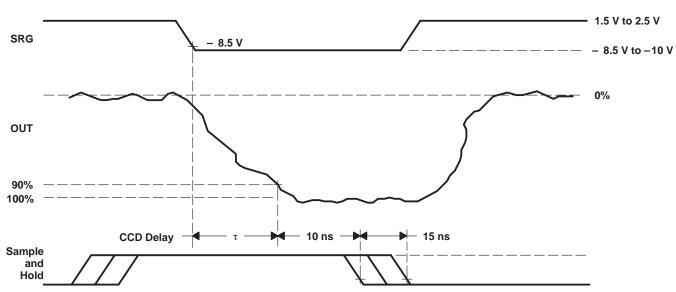
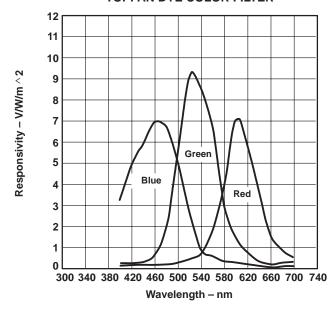
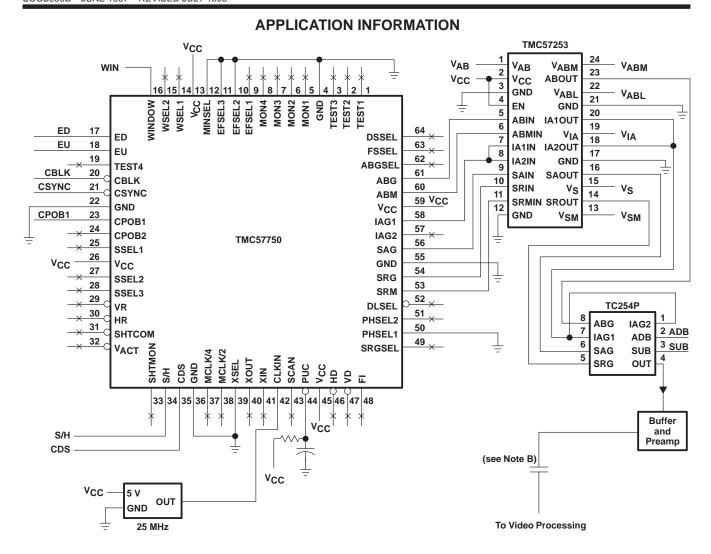


Figure 8. SRG and CCD Output Waveforms

TYPICAL CHARACTERISTICS

TC254 SPECTRAL RESPONSE WITH CM500 TOPPAN DYE COLOR FILTER





DC VOLTAGES				
VIA, VSM, VS	12 V			
V _{CC}	5 V			
ADB	22 V			
SUB	10 V			
V _{ABM}	7.5 V			
V _{AB}	14 V			
V _{ABL}	3 V			

Figure 9. Typical Application Circuit Diagram

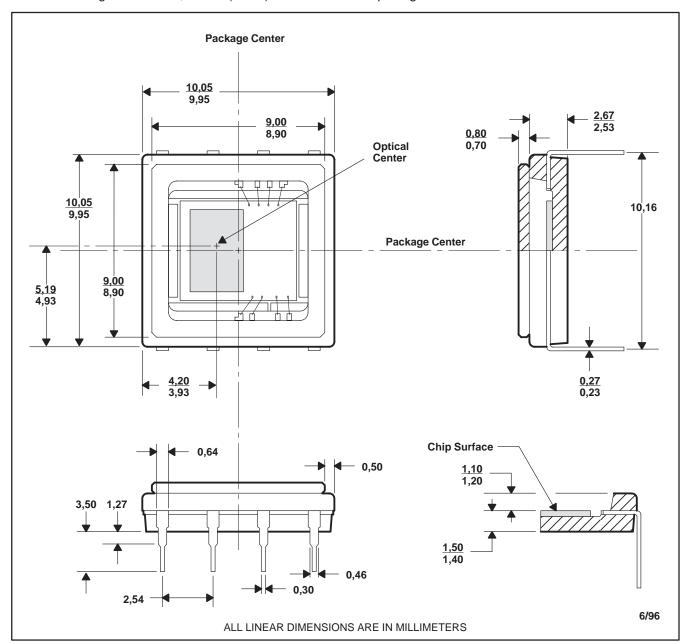
NOTES: A. Decoupling capacitors are not shown.

B. TI recommends designing AC coupled systems.



MECHANICAL DATA

The package for the TC254P consists of a plastic base, a glass window, and an 8-lead frame. The glass window is sealed to the package by an epoxy adhesive. The package leads are configured in a dual in-line organization and fit into mounting holes with 2,54 mm (0.1 in) center-to-center spacings.



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